

Confinement and Processing Can Alter the Morphology and Periodicity of Bottlebrush Block Copolymers in Thin Films

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Supporting Information

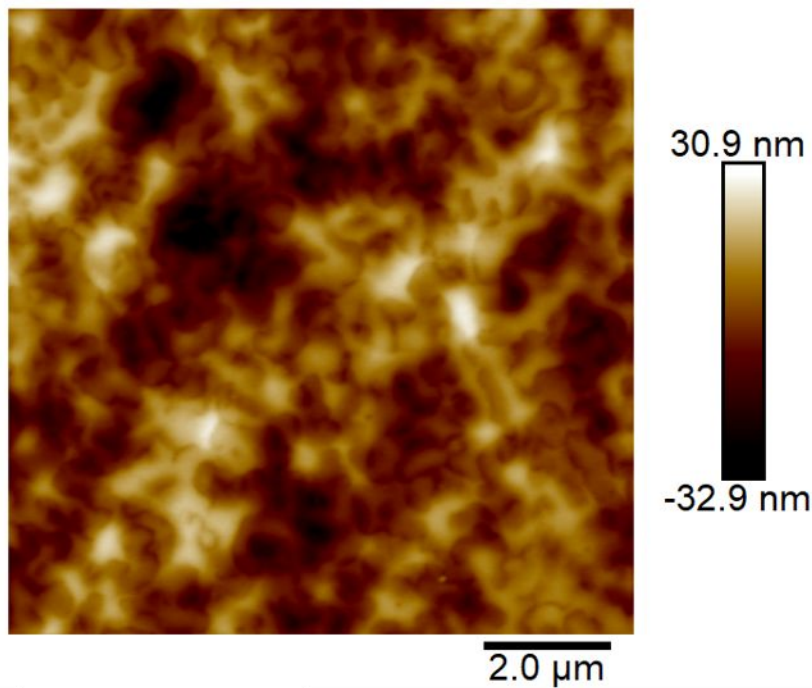
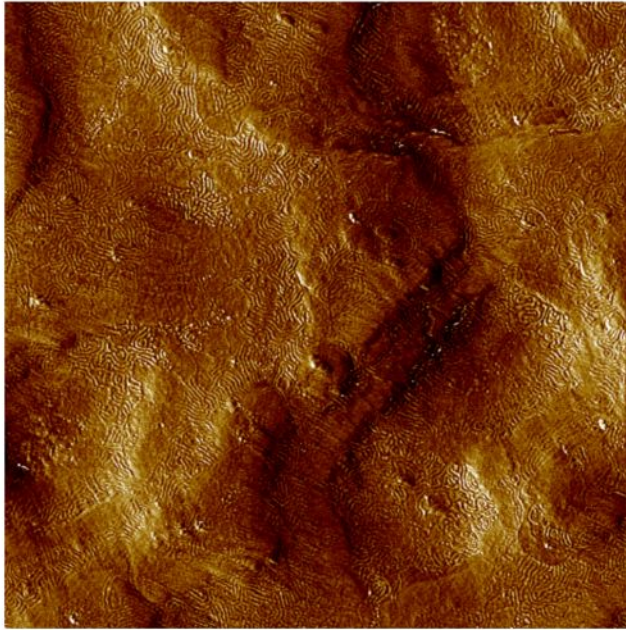
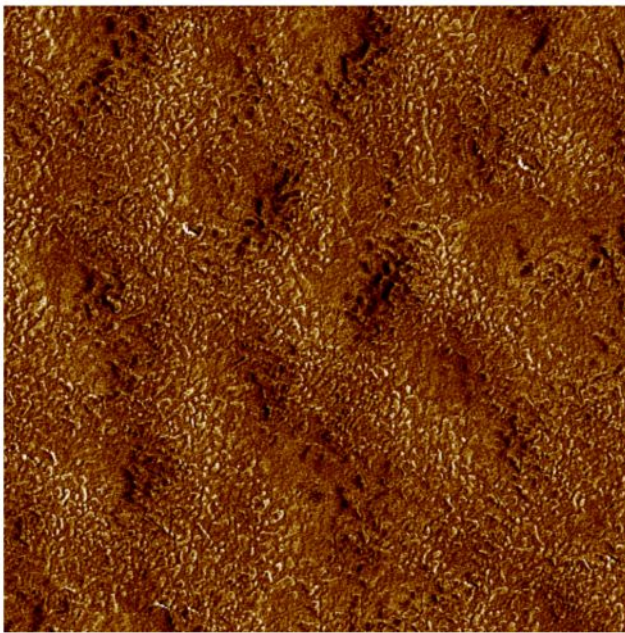


Figure S1: AFM height image of gPS-*b*-gPLA blade coated out of a THF solution at a thickness of 90 nm prior to annealing.



2.0 μm

Figure S2: AFM phase image of gPS-*b*-gPLA blade coated out of a THF solution at a thickness of 110 nm after annealing at 165 °C for 24 hrs.



2.0 μm

Figure S3: AFM phase image of gPS-*b*-gPLA blade coated out of a THF solution at a thickness of 50 nm after annealing at 165 °C for 24 hrs. The PSD yields a broad peak centered around 85 nm.